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Direct Photoassisted a-Trifluoromethylation of Aromatic Ketones with Trifluoroacetic Anhydride (TFAA)

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Abstract. Direct α -Trifluoromethylation of acetophenone derivatives was achieved by using trifluoroacetic anhydride (TFAA) as the trifluoromethyl source and pyridine-*N*-oxide (Py-O) as activator and oxidant under visible light irradiation and tris-(2,2'-bipyridine)ruthenium(II) hexafluorophosphate (Ru(bpy)₃(PF₆)₂) as the photocatalyst. Different acetophenone derivatives could be converted to the corresponding α -CF₃ derivatives with high selectivity. Extensive mechanistic investigation revealed the formation of vinyl trifluoroacetate as the key intermediate for this transformation.

Keywords: Trifluoromethylation; Fluorinated organic compounds; Photoredox catalysis; Aromatic ketone; Trifluoroacetic anhydride.

Fluorinated organic compounds are particularly important molecules because of their widespread application in pharmaceuticals and agrochemicals. In fact, 20-30% of modern pharmaceuticals and agrochemicals contain at least one fluorine atom.^[1] One approach of incorporating fluorine atom in organic molecules is via the installation of trifluoromethyl (CF₃) group which can have a pharamacokinetic influence on the profound properties of the molecules.^[2] Many elegant approaches for the trifluoromethylation of organic molecules^[3] using electrophilic,^[4] nucleophilic^[5] and radical^[6] sources are now available. Despite this, most of the reagents available for this purpose are expensive and a large-scale application would be limited due to availability and costs. Thus, the development of new trifluoromethylation methods applying cheap and abundant CF_3 sources will be very useful in synthetic chemistry.^[7]

 α -CF₃ carbonyl compounds are valuable building blocks for the synthesis of various complex CF₃ containing molecules.^[8] Different approaches for the

synthesis of such molecules have been reported, either directly from the ketones or from other starting materials.^[9] The most common strategies for the synthesis of α -trifluoromethylated carbonyl compounds from carbonyl molecules usually are based on the two steps shown in **Scheme 1a**. Enolates derived from the ketones are reacted with either a radical CF₃ or an electrophilic CF₃ source to provide the α -CF₃ products.^{[10][11]}

a) two steps approach for α -trifluoromethylation of ketones (ref 9-13)

$$\begin{array}{c} O \\ H_{3} \end{array} \xrightarrow{O} \\ R \end{array} \xrightarrow{O} \\ M = Na, Li \text{ or } SIR_{3} \end{array} \xrightarrow{CF_{3} \text{ or } CF_{3}^{\oplus}}_{(radical initiator (for SO_{2}CF_{3}))} \\ R \end{array} \xrightarrow{O} \\ R \end{array}$$

b) Photoassisted C-H trifluoromethylation using TFAA (ref 14)



Scheme 1. a) Trifluoromethylation of ketones using radical or electrophilic CF₃ sources as reported in the literature; b) photoredox C-H trifluoromethylation of aromatics using TFAA as CF₃ source as reported by Stephenson's group; c) our work on the direct α -trifluoromethylation of acetophenones *via* the *in situ* formation of vinyl trifluoroacetate.

Several reports on the α -C-H trifluoromethylation of carbonyl compounds appeared in the last years. Macmillan *et al* achieved an α -trifluoromethylation of ketones *via* the reaction of silyl enol ether and CF₃I as the CF₃ source under photoassisted conditions.^[12] Recently, Kamimura *et al.* have shown another interesting protocol for the synthesis of α -CF₃ ketones.^[13] Vinyl triflates derived from a ketone can be rearranged to α -CF₃ carbonyl compounds in the presence of a radical initiator, *e.g.* triethyl borane (BEt₃). The same rearrangement can also be performed by photocatalysis as shown by Liu *et al.*^[14] Despite these advancements, most of the reported procedures use CF₃-sources which are expensive and all these procedures are based on a two-step approach for the trifluoromethylation of ketones.

Stephenson's Recently, group reported а trifluoromethylation protocol photoredox using trifluoroacetic anhydride (TFAA) as CF3 source and pyridine N-oxide 1 (Py-O) as the activator for TFAA as well as the oxidant.^[15] Using Ru(bpy)₃(Cl)₂ as the photocatalyst, they achieved trifluoromethylation of a series of electron-rich aromatics and heteroaromatics under mild conditions (Scheme 1b). TFAA is a cheap and easily available CF3 source, thus expansion of this protocol could be valuable for the synthesis of other CF₃-containing molecules. Inspired by their report. we were wondering if this trifluoromethylation approach could be extended for the synthesis of other CF₃-containing building blocks. In particular, the target was the α trifluoromethylation of acetophenone derivatives. We envisioned that in the presence of TFAA and Py-O, the trifluoroacetate 4 can be generated in situ, which can react with the CF₃ radical under photochemical condition to provide the α -CF₃ product **3**. Herein, we trifluoromethylation report this direct of acetophenone derivatives using the TFAA/Py-O system under photoassisted condition.

Table 1. Initial screening results for the α -trifluoromethylation of 4-fluoroacetophenone.

F 2a	O CH ₃ TFAA, F Ru(bpy) ₃ Blue light, 24 I	Py-O, (PF ₆) ₂ MeCN F	O CF ₃ + 3a	CF ₃ 5
Entry ^{a)}	TFAA/Py-O (eq.)	Temp.	Conversion ^{b)}	3a/5
1	2.2/2.0	RT	-	-
2	4.4/4.0	RT	30%	1/3
3	4.4/4.0	50 °C	34 %	3.5/1
4	4.4/4.0	65 °C	57%	9/1
5 ^{c)}	4.4/4.0	65 °C	52%	12/1
6	5.5/5.0	65 °C	85%	100/-
7 ^{d)}	4.4/4.0	65 °C	0%	-
8 ^{e)}	4.4/4.0	65 °C	0%	-

^{a)} 0.25 mmol of substrate was used in 1.5 mL MeCN. ^{b)} Conversion refers to the total conversion of **2a** to products (**3a** + **5**) and was determined from GC after work up with an aq. NaHCO₃ solution. ^{c)} Ru(bpy)₃(Cl)₂.6H₂O was used

as the catalyst. ^{d)} The reaction was carried out in the dark. ^{e)} No photocatalyst.

To start these investigations, 4-fluoroacetophenone was used as the model substrate 2a and $Ru(bpy)_3(PF_6)_2$ as the photocatalyst. The use of 2 eq. of Py-O and TFAA at room temperature did not provide any significant conversion of the substrate 2a after 24 h. Twice the amount of TFAA/Py-O provided 30% conversion. Unfortunately, we obtained a mixture of both the α -CF₃ product **3a** as well as the trifluoromethylation product 5 (Table 1, entries 1-2). Interestingly, increasing the temperature from RT to 50 °C increased the conversion and the selectivity towards the α -CF₃ product **3a** (entry 3). Increasing the temperature further to 65 °C, provided reasonable conversion and good selectivity to the α -CF₃ product **3a** (entry 4). Changing th∩ photocatalyst from Ru(bpy)₃(PF₆)₂ to Ru(bpy)₃(Cl)₂ under otherwise similar condition, gave a slightly lower yield (entry 5). The conversion could be further increased by using 5.5 eq. of TFAA and 5.0 eq. of Py-O (entry 6). Under these conditions, no aromatic trifluoromethylation product 5 was observed. Addition of external bases e.g. K₃PO₄ or Na₂CO₃ did not improve the conversion (see SI Table S1, page 3 for full optimisation and screening). Control experiments showed no conversion to the product in the absence of light or catalyst (entries 7-8).



Scheme 2. Substrate scope for the α -trifluoromethylation of acetophenones under photoassisted conditions using TFAA as CF₃ source and Ru(bpy)₃(PF₆)₂ as the photocatalyst. Isolated yields after the chromatographic purification.

With the optimised reaction conditions for the α trifluoromethylation of **2a** in hand, we next examined the substrate scope for this method. Different acetophenone derivatives were screened under the optimised reaction conditions. Similar isolated yields were obtained for the different 4-halo-substituted acetophenones to their corresponding CF₃ products. For p-CF₃ acetophenone, the conversion was only 44% (from ¹H NMR) and the isolated yield of the product 3d was 30%. Other acetophenone derivatives gave similar yields of the products as shown in Scheme 2; e.g. for 3-chloro and 2-Me acetophenones, the yield obtained for the corresponding α -CF₃ products **3e** and **3f** were 51% and 64% respectively. While acetophenone as substrate gave the corresponding product 3g 60% in vield, 2-acetopnaphthone provided only 33% of the corresponding product 3h. Also, in the case of indanone, the product 3j was obtained in very low yield. When cyclohexanone or dimethyl malonate were used as substrates, no corresponding α -CF₃ products were obtained under these conditions.

 Table 2. Optimisation study for the vinyl trifluoroacetate 4



formation in the presence of TFAA and Py-O.

Entry ^{a)}	TFAA (eq.)	Py-O (eq.)	Temp.	Conversion ^{b)}
1	4	1	RT	2%
2	2	1	65 °C	34%
3	5	1	65 °C	60%
4	5	0	65 °C	0%
5	5	2	65 °C	89%
6	5	3	65 °C	97%
7	5	4	65 °C	quant.

^{a)} All reactions were carried out in 0.25 mmol scale in 1.5 mL of CD₃CN. ^{b)} Conversions are given relative to the product and were measured from ¹H NMR of the crude reaction mixture.

To investigate the role of TFAA and Py-O for this transformation, the initial step of the reaction in the dark which involves the formation of vinyl trifluoroacetate **4** was examined. As shown in Table **2**, no vinyl trifluoroacetate **4** is formed at room temperature, which explained the low conversion under ambient conditions. Higher temperatures accelerate the formation of **4** and the formation of **4** was completely stopped in the absence of pyridine N-oxide. Almost 5.0 eq. of TFAA and 4.0 eq. of Py-O are required for the quantitative conversion of the substrate **2a** to the vinyl trifluoroacetate **4**. This can explain the necessity of the demand for the excess of TFAA and Py-O to obtain reasonable conversions and yields.

Interestingly, this vinyl trifluoroacetate **4** reacted smoothly under photoassisted condition to provide the α -CF₃ product **6** at room temperature (**Scheme 3a**, also see SI **Figure S1**, page 10 for more details). As from the first step there was already Py-O and TFAA present in the crude reaction mixture, this experiment could not provide any details about the role of Py-O and TFAA for the second step of the reaction.

To examine the role of TFAA/Py-O for the formation of the product 3a from the vinyl trifluoroacetate 4, the vinyl trifluoroacetate 4 was prepared *in situ* using 2,6-di-*t*Bu-4-Me pyridine as the base^[16] (Scheme 3). When 4 was treated under photoassisted conditions in the absence of TFAA, in contrast to the vinyl triflates as shown by Lie *et al*,^[14]no rearrangement to **3a** could be observed. Also, no product was formed when 4 was treated under photoassisted conditions in the presence of Py-O. The product formation only occurred when both reagents TFAA and Py-O were present in the requirement for an excess of both the reagents TFAA and Py-O for achieving good yields of the α -CF₃ product.



Scheme 3. Synthesis of vinyl trifluoroacetate **4** and subsequent control reactions.

Based on the observations described above and following literature reports, the mechanism as shown in Scheme 4 can be proposed, exemplified by 4fluoro acetophenone 2a as the substrate. First, vinyl trifluoroacetate 4 is formed from the acetophenone 2a. This step requires both reagents TFAA and Py-O as well as higher temperature. This step is a light independent reaction. The second step is the photoassisted cycle, where the formed vinyl trifluoroacetate 4 will trap the CF₃ radical formed from the pyridinium intermediate A as proposed by Stephenson's group.^[15] Oxidation of this radical by Ru(III) will form the carbocation **D**. This will be captured by the trifluoroacetate anion to form the trifluoroacetyl-protected acetal 6. This compound upon work up will give the product 3a.



Scheme 4. Mechanistic proposal for the photoassisted α -trifluoromethylation of acetophenones with TFAA exemplified by 4-fluoroacetophenone as the substrate.

In summary, we achieved the direct α -trifluoromethylation of aromatic ketones under photoassisted conditions. This method utilizes TFAA as CF₃ source and pyridine-*N*-oxide as oxidant. Because of the low cost and the availability of these materials, we expect that this method will find numerous applications for the synthesis of α -CF₃ ketones.

Experimental Section

In a 4 mL screw-capped vial with a rubber septum, 4-fluoroacetophenone (60 µl, 0.5 mmol), pyridine-*N*-oxide (240 mg, 2.5 mmol), Ru(bpy)₃(PF₆)₂ (13.0 mg, 0.015 mmol) were dissolved in 2 mL dry MeCN. The vial was closed and degassed by bubbling argon for 30 sec. Trifluoroacetic anhydride (480 µl, 3.5 mmol) was added to the reaction mixture and stirred for 16 h at 65 °C under blue light irradiation (435-445 nm, 500 mA, 5-6 watts). After this time, the reaction mixture was quenched by adding 10 mL sat. aq. NaHCO₃ solution and extracted with EtOAc (3 X 15 mL). The organic layer was dried using anhydrous MgSO₄ and concentrated *in vacuo*. The pure product was obtained after the chromatographic purification as colorless oil. Yield: 64%; 66 mg. R_f = 0.22 (5% EtOAc in pet ether); ¹H NMR (301 MHz, CDCl₃) δ 8.00 – 7.92 (m, 1H), 7.21 – 7.13 (m, 1H), 3.76 (q, J = 9.9 Hz, 1H); ¹³C NMR (76 MHz, CDCl₃) δ 188.11 (q, *J* = 2.5 Hz), 166.37 (d, *J* = 257.1 Hz), 132.30 (dq, *J* = 3.2, 1.7 Hz), 131.17 (d, *J* = 9.6 Hz), 123.86 (q, *J* = 277.0 Hz), 116.20 (d, *J* = 22.2 Hz), 42.14 (q, *J* = 28.4 Hz); ¹⁹F NMR (283 MHz, CDCl₃) δ -62.00 (s), -102.87 (s).

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References

- a) W. K. Hagmann, J. Med. Chem. 2008, 51, 4359-4369; b) N. A. Meanwell, J. Med. Chem. 2011, 54, 2529-2591; c) J. Wang, M. Sánchez-Roselló, J. L. Aceña, C. del Pozo, A. E. Sorochinsky, S. Fustero, V. A. Soloshonok, H. Liu, Chem. Rev. 2014, 114, 2432-2506; d) E. A. Ilardi, E. Vitaku, J. T. Njardarson, J. Med. Chem. 2014, 57, 2832-2842.
- [2] K. Müller, C. Faeh, F. Diederich, Science 2007, 317, 1881-1886.
- [3] Selected reviews: a) J.-A. Ma, D. Cahard, J. Fluorine Chem. 2007, 128, 975-996; b) T. Furuya, A. S. Kamlet, T. Ritter, Nature 2011, 473, 470-477; c) A. Studer, Angew. Chem. Int. Ed. 2012, 51, 8950-8958; Angew. Chem. 2012, 124, 9082-9090; d) C. Zhang, Adv. Synth. Catal. 2014, 356, 2895-2906; e) C. Zhang, Org. Biomol. Chem. 2014, 12, 6580-6589; f) L. Chu, F.-L. Qing, Acc. Chem. Res. 2014, 47, 1513-1522; g) X. Liu, C. Xu, M. Wang, Q. Liu, Chem. Rev. 2015, 115, 683-730; h) C. Alonso, E. Martínez de Marigorta, G. Rubiales, F. Palacios, Chem. Rev. 2015, 115, 1847-1935; i) J. Charpentier, N. Fruh, A. Togni, Chem Rev 2015, 115, 650-682; i) X. Pan, H. Xia, J. Wu, Org. Chem. Front. **2016**, *3*, 1163-1185; j) C. Zhang, Adv. Synth. Catal. 2017, 359, 372-383; k) Y. Zhao, F. Liu, Tetrahedron Lett. 2018, 59, 180-187; 1) H.-X. Song, Q.-Y. Han, C.-L. Zhao, C.-P. Zhang, Green Chem. 2018, 20, 1662-1731; m) T. Koike, M. Akita, Chem 2018, 4, 409-437.
- [4] Selected recent reports for electrophilic trifluoromethylation: a) F. Gelat, A. Patra, X. Pannecoucke, A. T. Biju, T. Poisson, T. Besset, Org. Lett. 2018, 20 3897-3901; b) W. Yang, D. Ma, Y. Zhou, X. Dong, Z. Lin, J. Sun, Angew. Chem. Int. Ed. 2018, 57, 12097 12101; Angew. Chem. 2018, 130, 12273-12277; c) D. Katayev, H. Kajita, A. Togni, Chem. Eur. J. 2017, 23. 8324-8324; d) D. Katayev, V. Matoušek, R. Koller, A. Togni, Org. Lett. 2015, 17, 5898-5901; e) A. Prieto, O. Baudoin, D. Bouyssi, N. Monteiro, Chem. Commun. 2016, 52, 869-881.
- [5] Selected recent reports for nucleophilic trifluoromethylations: a) B. Musio, E. Gala, S. V. Ley, ACS Sustain. Chem. Eng. 2018, 6, 1489-1495; b) J. A. Pike, J. W. Walton, Chem. Commun. 2017, 53, 9858-9861; c) G. K. S. Prakash, F. Wang, Z. Zhang, R. Haiges, M. Rahm, K. O. Christe, T. Mathew, G. A. Olah, Angew. Chem. Int. Ed. 2014, 53, 11575-11578; Angew. Chem. 2014, 126, 11759-11762.
- [6] Selected recent reports for radical trifluoromethylation:
 a) S. Zhou, T. Song, H. Chen, Z. Liu, H. Shen, C. Li, Org. Lett. 2017, 19, 698-701; b) L. Wu, F. Wang, X. Wan, D. Wang, P. Chen, G. Liu, J. Am. Chem. Soc. 2017, 139, 2904-2907; c) F. Wang, D. Wang, Y. Zhou, L. Liang, R. Lu, P. Chen, Z. Lin, G. Liu, Angew. Chem. Int. Ed. 2018, 57, 7140-7145; Angew. Chem. 2018, 130, 7258-7263; d) Y. Xu, Z. Wu, J. Jiang, Z. Ke, C. Zhu, Angew. Chem. Int. Ed. 2017, 56, 4545-4548; Angew. Chem. 2017, 129, 4616-4619; e) B. Chang, Y. Su, D. Huang, K.-H. Wang, W. Zhang, Y. Shi, X. Zhang, Y. Hu, J. Org. Chem. 2018, 83, 4365-4374; f) Y. Ouyang, X.-H. Xu, F.-L. Qing, Angew. Chem. Int. Ed. 2018, 130, 7042-7045; g) A.

K. Pal, C. Li, G. S. Hanan, E. Zysman-Colman, Angew. Chem. Int. Ed. 2018, 57, 8027-8031; Angew. Chem.
2018, 130, 8159-8163; h) C. Le, T. Q. Chen, T. Liang, P. Zhang, D. W. C. MacMillan, Science 2018, 360, 1010-1014.

- [7] a) T. Schareina, X.-F. Wu, A. Zapf, A. Cotté, M. Gotta, M. Beller, Top. Catal. 2012, 55, 426-431; b) A. Lishchynskyi, M. A. Novikov, E. Martin, E. C. Escudero-Adán, P. Novák, V. V. Grushin, J. Org. Chem. 2013, 78, 11126-11146; c) X. Lin, C. Hou, H. Li, Z. Weng, Chem. Eur. J. 2016, 22, 2075-2084; d) M. Chen, S. L. Buchwald, Angew. Chem. Int. Ed. 2013, 52, 11628-11631; Angew. Chem. 2013, 125, 11842-11845; e) G. Shi, C. Shao, S. Pan, J. Yu, Y. Zhang, Org. Lett. 2015, 17, 38-41; f) J. Lin, Z. Li, J. Kan, S. Huang, W. Su, Y. Li, Nat. Commun. 2017, 8, 14353; g) S. Zhong, A. Hafner, C. Hussal, M. Nieger, S. Bräse, RSC Adv. 2015, 5, 6255-6258; h) S. Kawamura, M. Sodeoka, Angew. Chem. Int. Ed. 2016, 55, 8740-8743; Angew. Chem. 2016, 128, 8882-8885; i) J. B. Geri, N. K. Szymczak, J. Am. Chem. Soc. 2017, 139, 9811-9814; j) J. B. Geri, M. M. Wade Wolfe, N. K. Szymczak, Angew. Chem. Int. Ed. 2018, 57, 1381-1385; Angew. Chem. 2018, 130, 1395-1399.
- [8] a) Y. Itoh, M. Yamanaka, K. Mikami, Org. Lett. 2003, 5, 4807–4809; b) M. Schlosser, Angew. Chem. Int. Ed. 2006, 45, 5432–5446; Angew. Chem. 2006, 118,5558–5572.
- [9] a) P. Novák, A. Lishchynskyi, V. V. Grushin, J. Am. Chem. Soc. 2012, 134, 16167-16170; b) A. Deb, S. Manna, A. Modak, T. Patra, S. Maity, D. Maiti, Angew. Chem. Int. Ed. 2013, 52, 9747-9750; Angew. Chem. 2013, 125, 9929-993; c) Z. Mazloomi, A. Bansode, P. Benavente, A. Lishchynskyi, A. Urakawa, V. V. Grushin, Org. Process Res. Dev. 2014, 18, 1020-1026; d) H.-T. Qin, S.-W. Wu, J.-L. Liu, F. Liu, Chem. Commun. 2017, 53, 1696-1699; e) C.-P. Zhang, Z.-L. Wang, Q.-Y. Chen, C.-T. Zhang, Y.-C. Gu, J.-C. Xiao, Chem. Commun. 2011, 47, 6632-6634; f) R. Tomita, Y. Yasu, T. Koike, M. Akita, Angew. Chem. Int. Ed. 2014, 53, 7144-7148; Angew. Chem. 2014, 126, 7272-7276; g) E. Yamaguchi, Y. Kamito, K. Matsuo, J. Ishihara, A.

Itoh, *Synthesis* **2018**, 3161-3168; h) Y. R. Malpani, B. K. Biswas, H. S. Han, Y.-S. Jung, S. B. Han, *Org. Lett.* **2018**, *20*, 1693-1697.

- [10] a) Y. Itoh, K. Mikami, Org. Lett. 2005, 7, 649-651; b)
 Y. Itoh, K. Mikami, J. Fluorine Chem. 2006, 127, 539-544; c) Y. Itoh, K. Mikami, Org. Lett. 2005, 7, 4883-4885; d) K. Mikami, Y. Tomita, Y. Ichikawa, K. Amikura, Y. Itoh, Org. Lett. 2006, 8, 4671-4673; e) Y. Itoh, K. N. Houk, K. Mikami, J. Org. Chem. 2006, 71, 8918-8925; f) D. Cantillo, O. de Frutos, J. A. Rincón, C. Mateos, C. O. Kappe, Org. Lett. 2014, 16, 896-899; g)
 D. A. Nagib, M. E. Scott, D. W. C. MacMillan, J. Am. Chem. Soc. 2009, 131, 10875-10877.
- [11] a) T. Umemoto, S. Ishihara, J. Am. Chem. Soc. 1993, 115, 2156-2164; b) T. Umemoto, K. Adachi, J. Org. Chem. 1994, 59, 5692-5699; c) J.-A. Ma, D. Cahard, J. Org. Chem. 2003, 68, 8726-8729; d) S. Noritake, N. Shibata, Y. Nomura, Y. Huang, A. Matsnev, S. Nakamura, T. Toru, D. Cahard, Org. Biomol. Chem. 2009, 7, 3599-3604; e) A. E. Allen, D. W. C. MacMillan, J. Am. Chem. Soc. 2010, 132, 4986-4987; f) V. Matoušek, A. Togni, V. Bizet, D. Cahard, Org. Lett. 2011, 13, 5762-5765.
- [12] P. V. Pham, D. A. Nagib, D. W. C. MacMillan, Angew. Chem. Int. Ed. 2011, 50, 6119-6122; Angew. Chem. 2011, 123, 6243-6246.
- [13] T. Kawamoto, R. Sasaki, A. Kamimura, Angew. Chem. Int. Ed. 2017, 56, 1342–1345; Angew. Chem. 2017, 129, 1362-1365.
- [14] S. Liu, J. Jie, J. Yu, X. Yang, Adv. Synth. Catal. 2018, 360, 267-271.
- [15] a) J. W. Beatty, J. J. Douglas, K. P. Cole, C. R. Stephenson, *Nat. Commun.* 2015, *6*, 7919; b) J. W. Beatty, J. J. Douglas, R. Miller, R. C. McAtee, K. P. Cole, C. R. J. Stephenson, *Chem* 2016, *1*, 456-472.
- [16] T. R. Forbus, Jr., S. L. Taylor, and J. C. Martin, J. Org. Chem. 1987, 52, 4156-4159.

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direct α-trifluoromethylation of acetophenone derivatives
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